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Lee

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(54) **LIQUID CRYSTAL DISPLAY DEVICE**
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(22) Filed: **Oct. 21, 2009**
(65) **Prior Publication Data**
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G02F 1/1343 (2006.01)
G02F 1/1345 (2006.01)
(52) **U.S. Cl.** **349/42**; 349/43; 349/46; 349/143;
349/149
(58) **Field of Classification Search** 349/39,
349/42, 43, 46, 143, 149
See application file for complete search history.

(57) **ABSTRACT**
A liquid crystal display device includes a first substrate which comprises a plurality of pixels where a thin film transistor and a pixel electrode electrically connected to the thin film transistor are formed, the first substrate including a gate line and a data line which insulatingly intersect each other; and a gate driver which applies a gate driving signal to the gate line, the thin film transistor including a gate electrode which is connected to the gate line; a source electrode which is connected to the data line; and a drain electrode which is connected to the pixel electrode, and the pixels being decreased in a value of $C_p/(C_p+C_{lc}+C_{st})$ as going toward the gate driver (where, C_p : a sum of parasitic capacity between the gate electrode and the source electrode and parasitic capacity between the gate electrode and the drain electrode, C_{lc} : liquid crystal capacity, and C_{st} : storage capacity).

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20 Claims, 18 Drawing Sheets

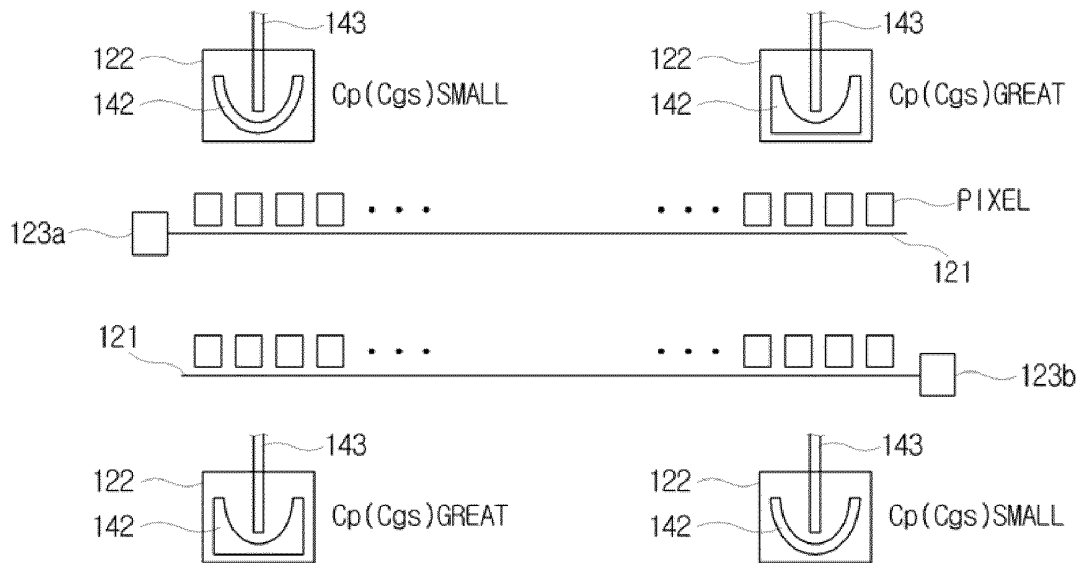


FIG. 1

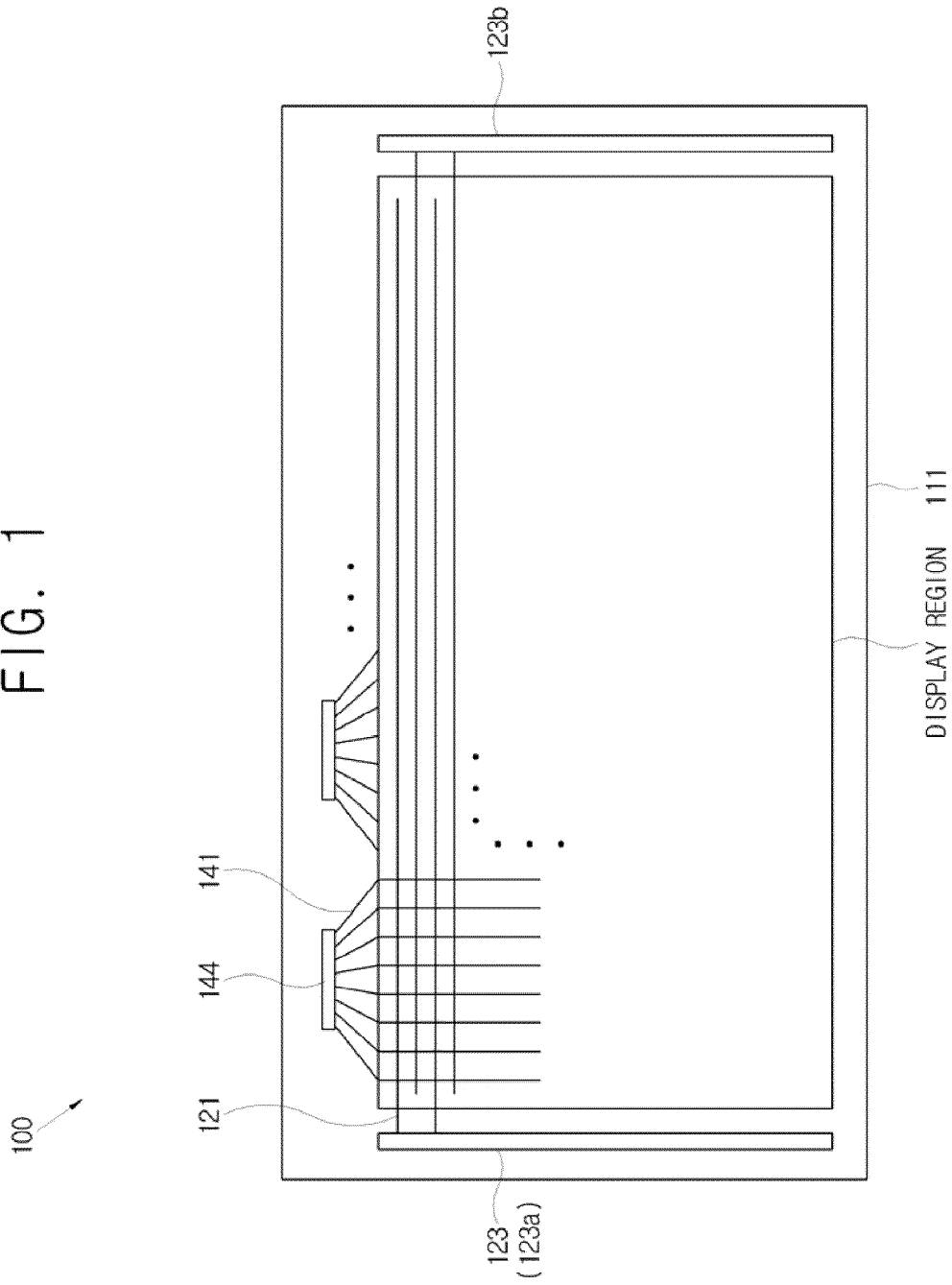


FIG. 2

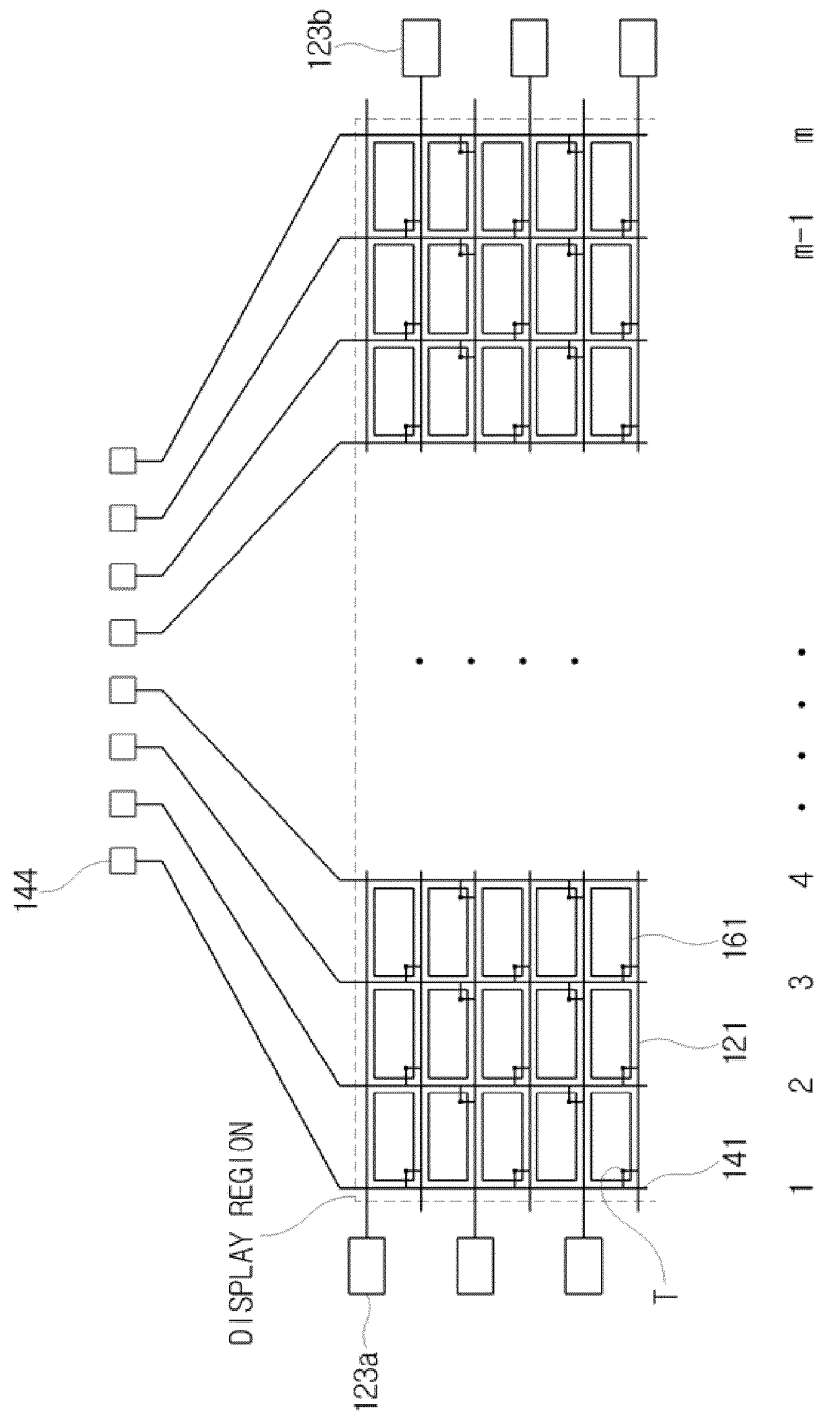


FIG. 3

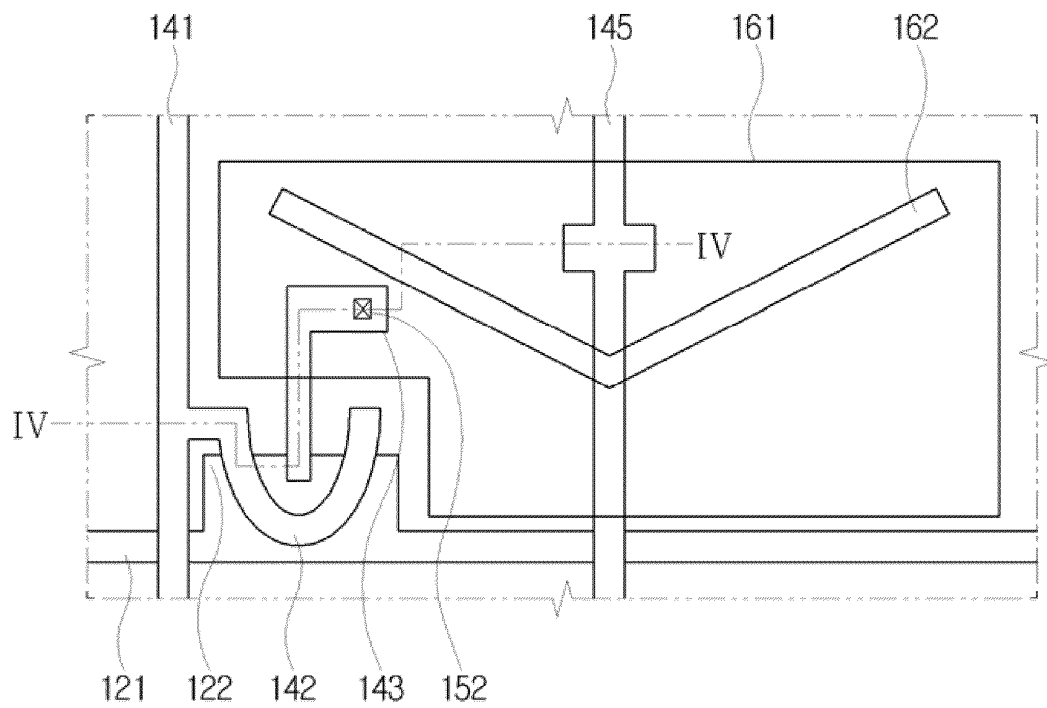


FIG. 4

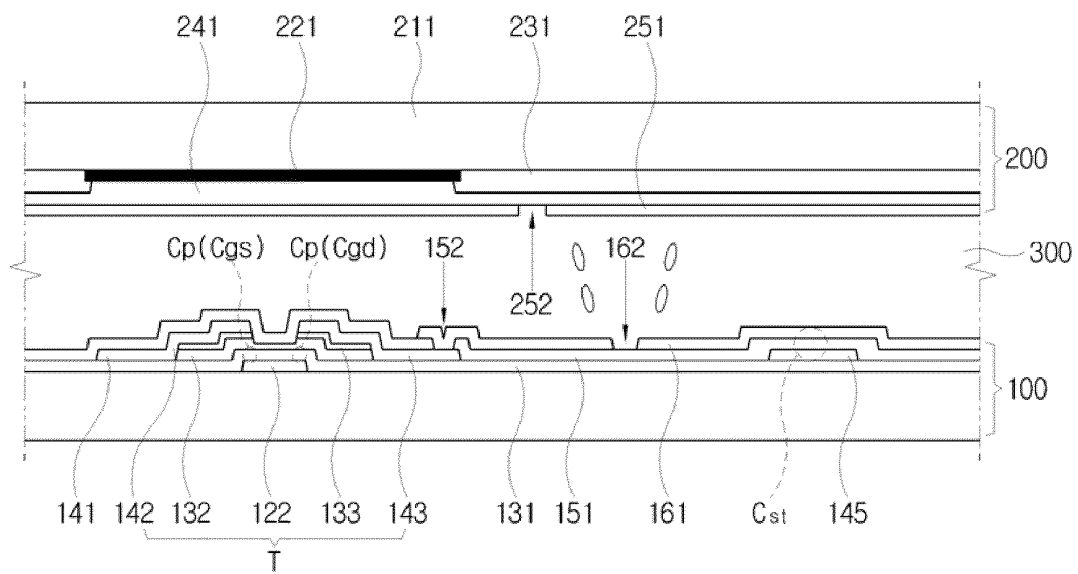


FIG. 5

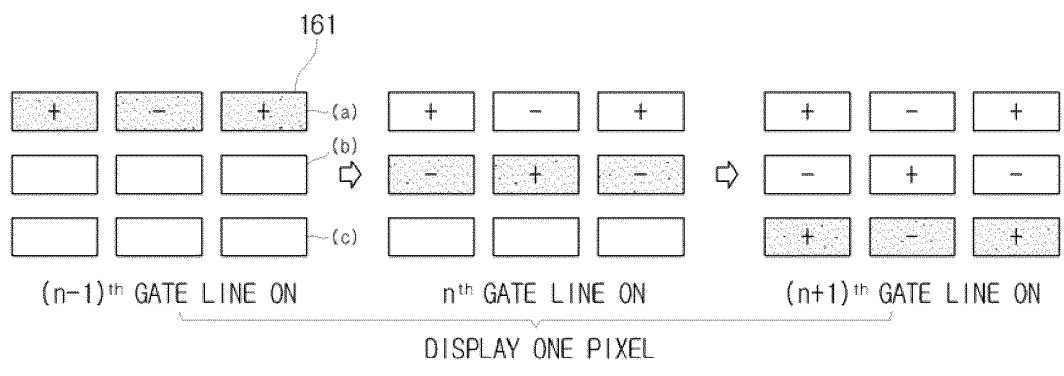


FIG. 6

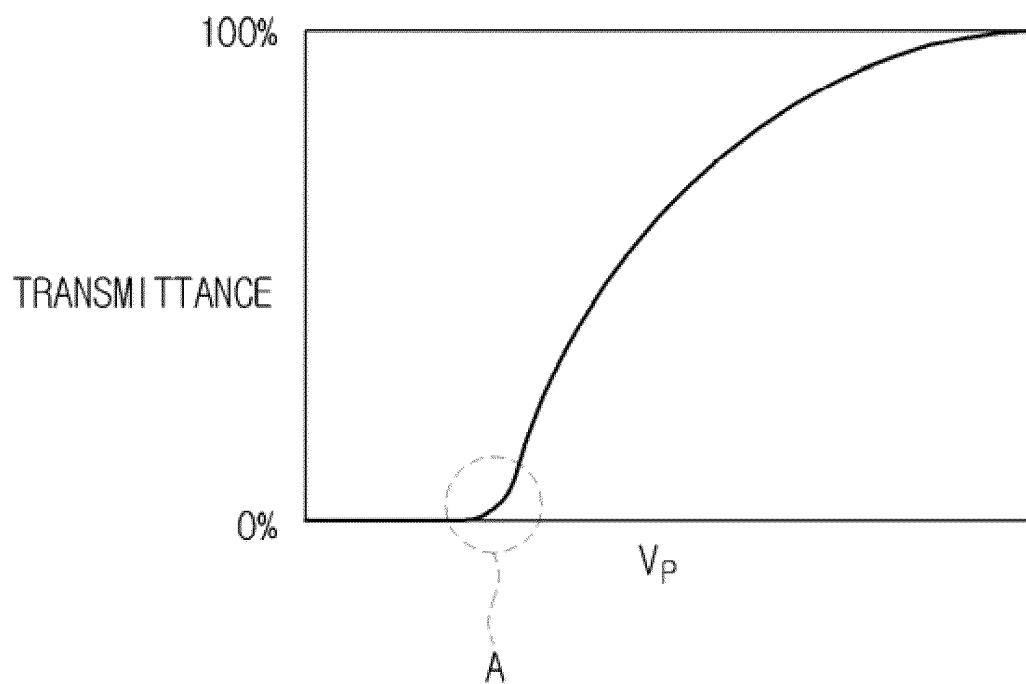


FIG. 7

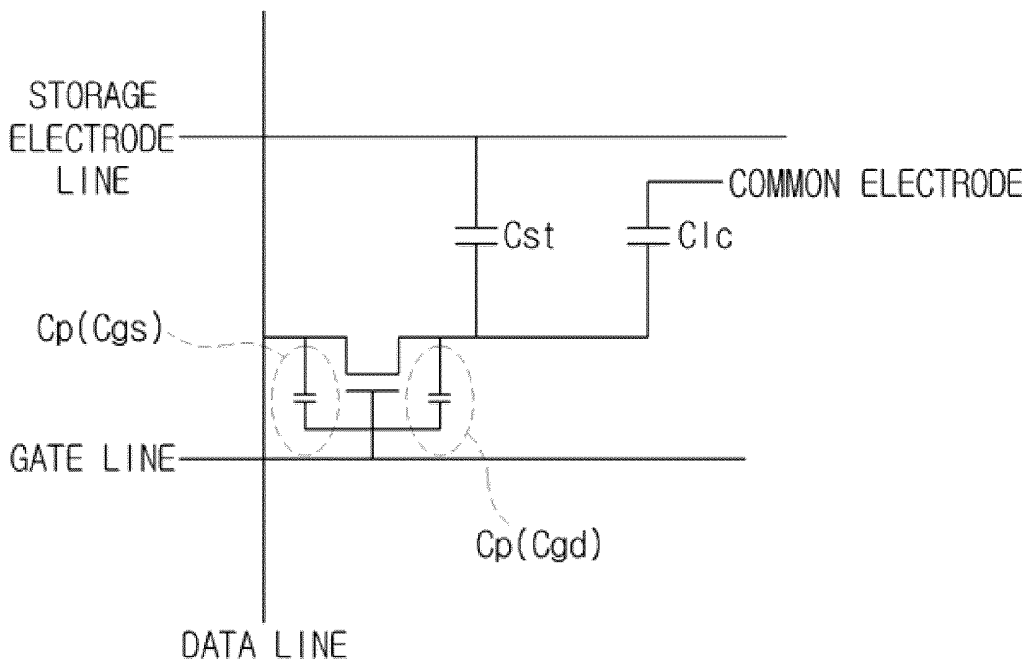


FIG. 8A

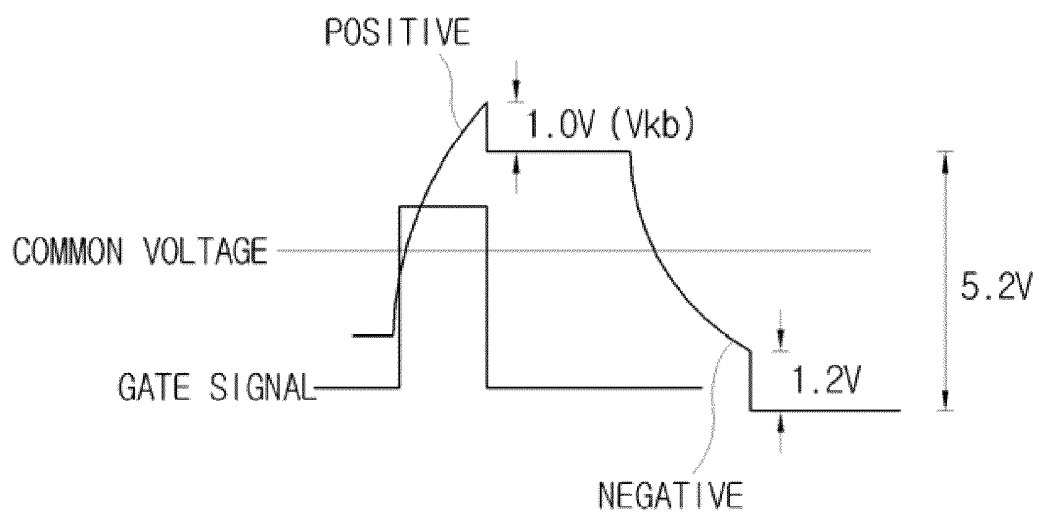


FIG. 8B

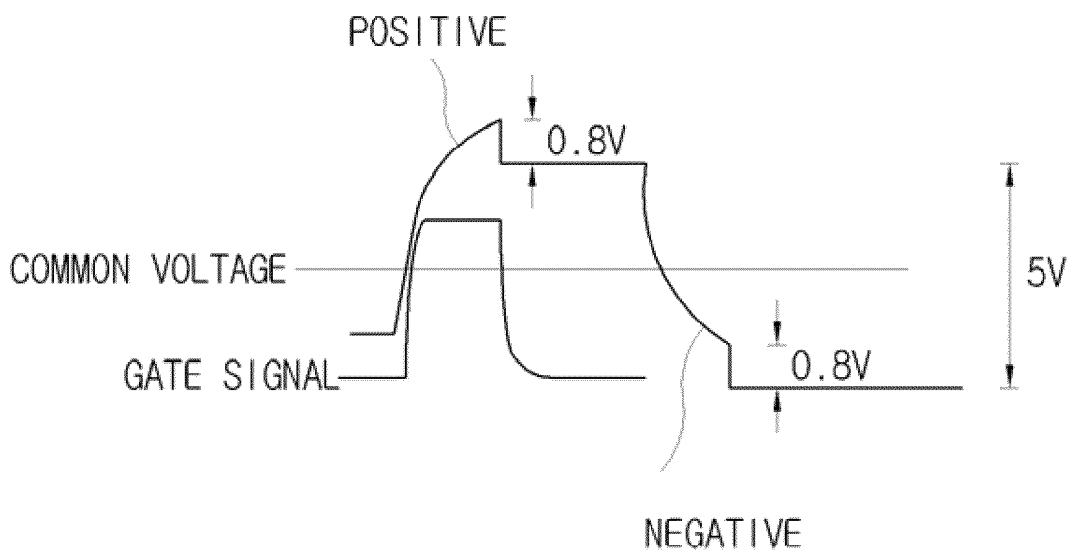


FIG. 8C

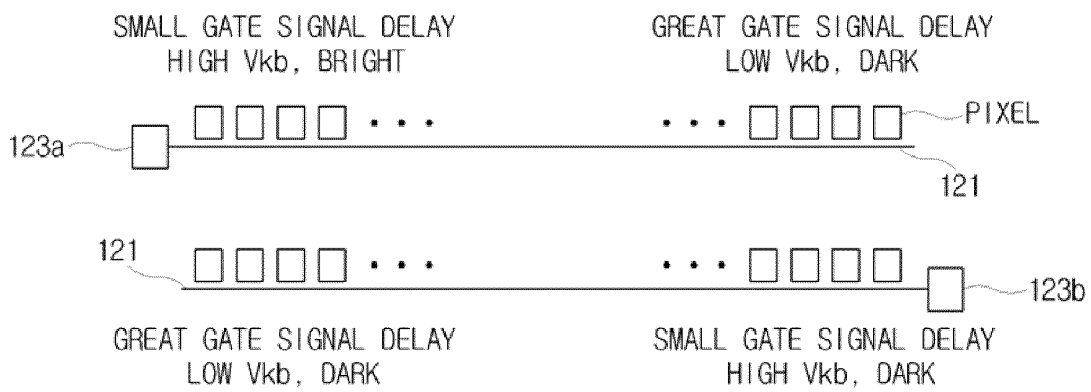


FIG. 9

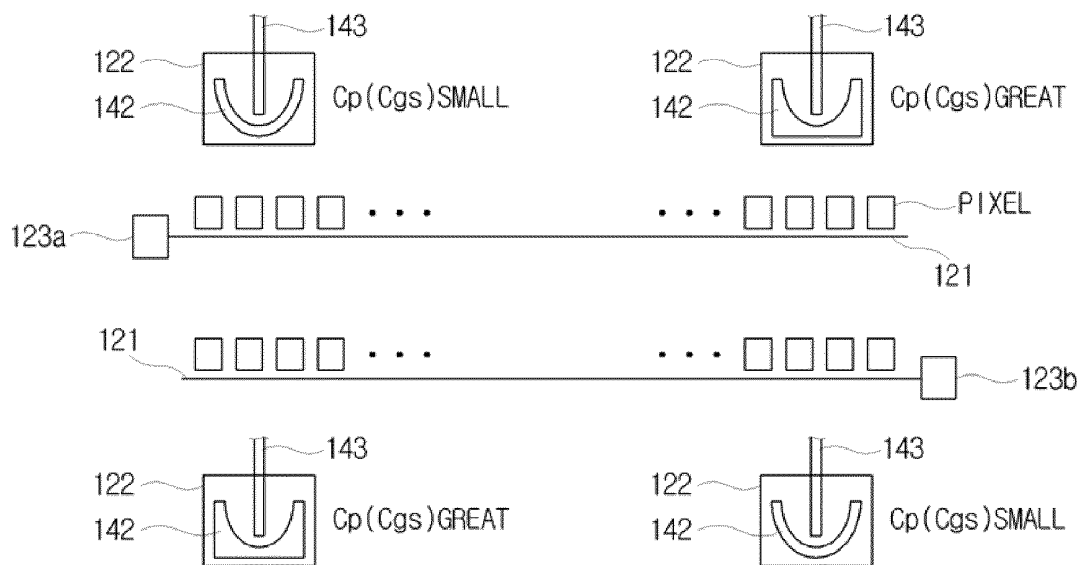


FIG. 10

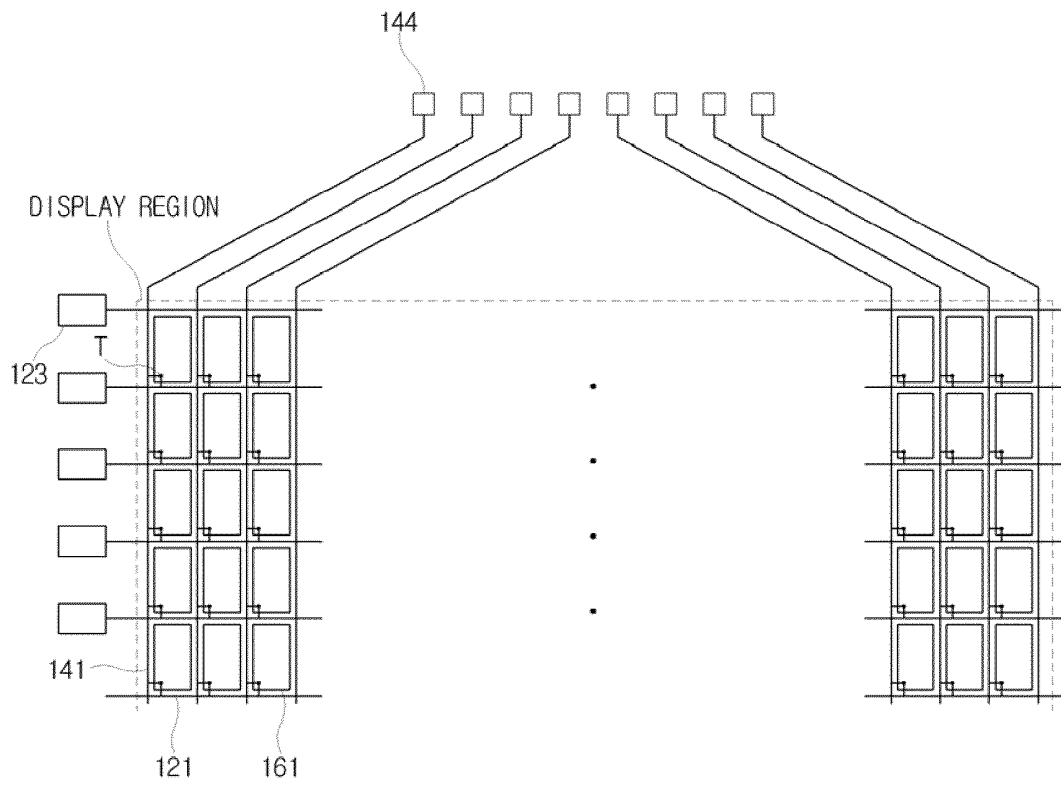


FIG. 11

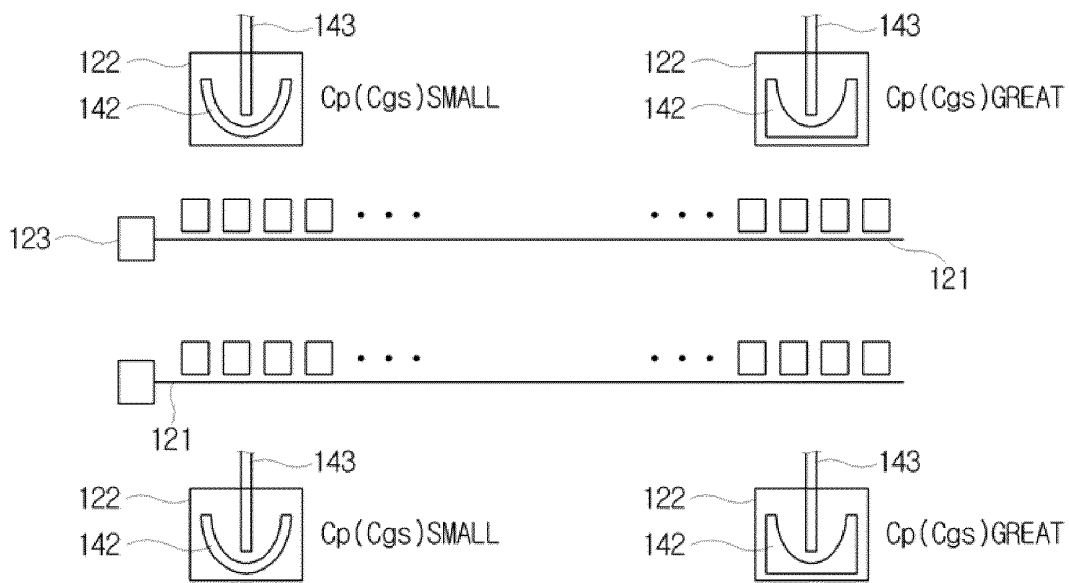


FIG. 12

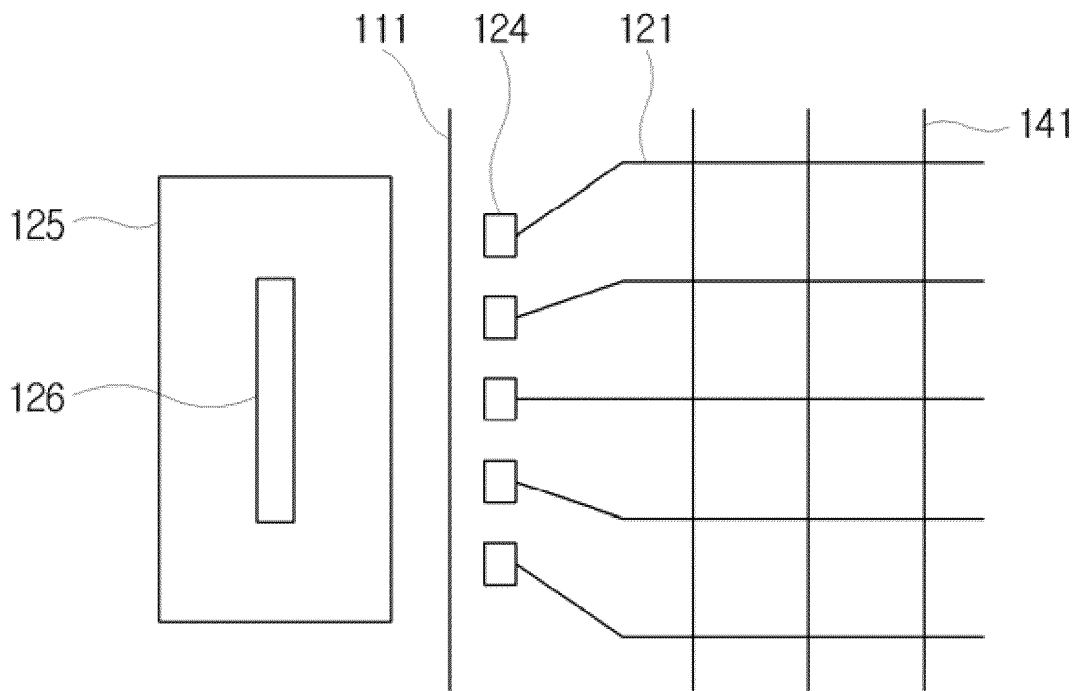


FIG. 13

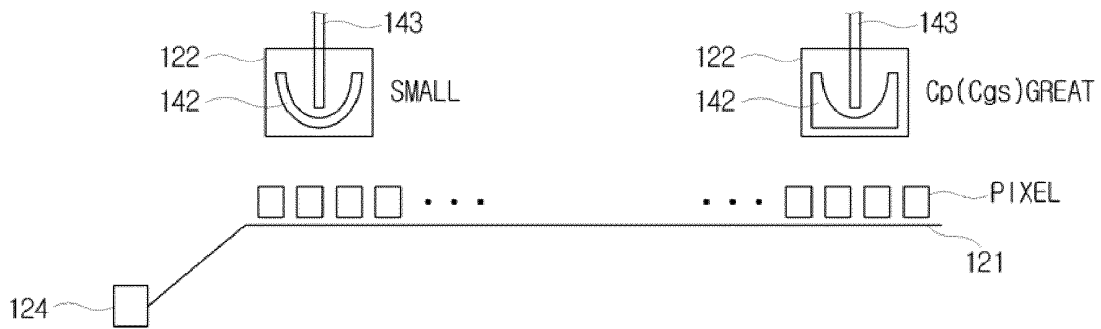


FIG. 14

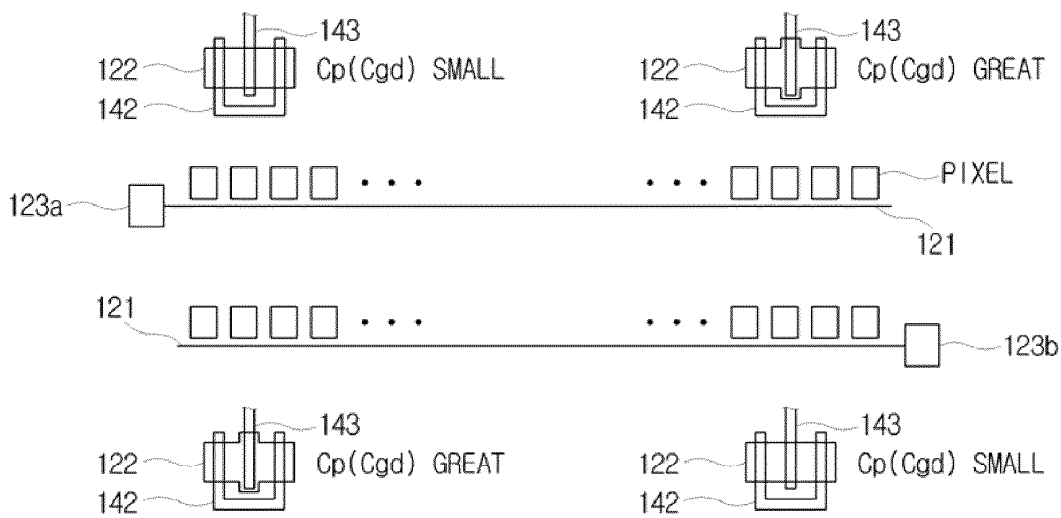


FIG. 15

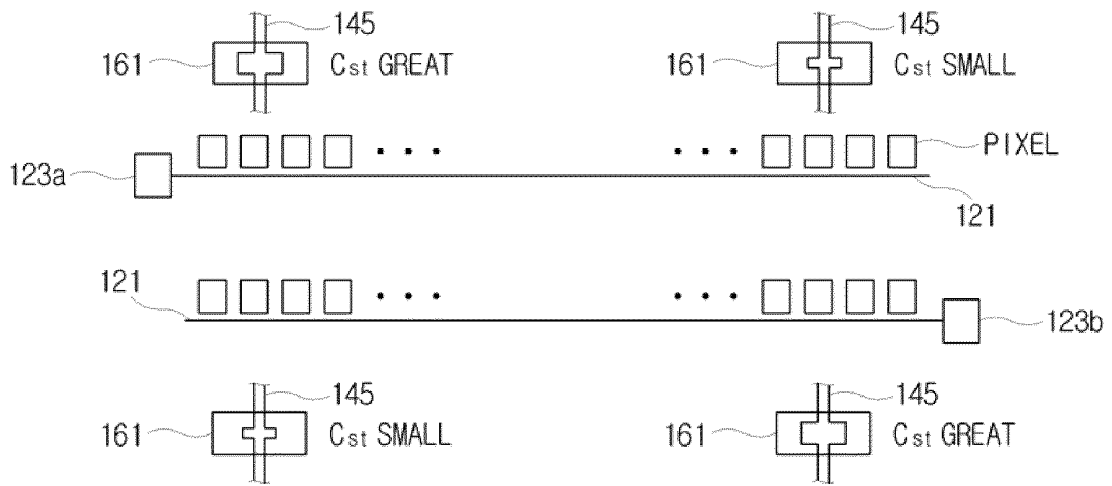
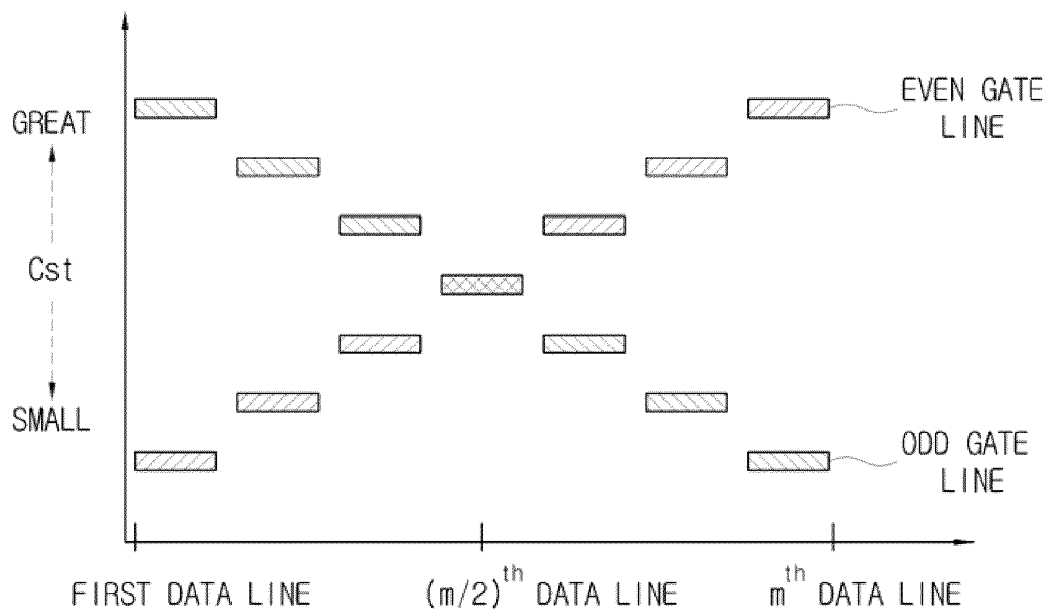


FIG. 16



LIQUID CRYSTAL DISPLAY DEVICE**CROSS-REFERENCE TO RELATED APPLICATIONS**

This application is a continuation of U.S. patent application Ser. No. 11/781,112, filed Jul. 20, 2007, which claims priority upon Korean Patent Application No. 2006-0086747, filed on Sep. 8, 2006 in the Korean Intellectual Property Office, the disclosure of which is incorporated herein by reference.

BACKGROUND OF INVENTION**1. Field of Invention**

Apparatuses and methods consistent with the present invention relate to a liquid crystal display device.

2. Description of the Related Art

A liquid crystal display (LCD) device includes a first substrate where thin film transistors are formed, a second substrate which is disposed opposite to the first substrate, and a liquid crystal layer disposed between the two substrates.

Gate lines and data lines are formed on the first substrate and insulatingly intersect each other to form pixels. The pixels are connected to the thin film transistors. When the gate lines receive a gate signal, i.e., a gate-on voltage V_{on} , to turn on the thin film transistors, a data voltage V_d applied through the data lines is charged in the pixels. Orientation of liquid crystal molecules in the liquid crystal layer is determined by an electric field between the pixel voltage V_p charged in the pixels and a common voltage on the common electrode. The data voltage V_d is applied with different polarities per frames.

The data voltage V_d applied to the pixels is reduced by parasitic capacity C_p between the gate electrode and the source electrode (drain electrode) to form the pixel voltage V_p . The voltage difference between the data voltage V_d and the pixel voltage V_p is the kickback voltage V_{kb} .

The gate lines receive a gate signal through a gate driver. Due to resistance in the gate lines, the pixel adjacent to the gate driver receives a gate signal which is less delayed, and the pixel far from the gate driver receives a gate signal which is significantly delayed.

The level of the kickback voltage varies depending on the delay of the gate signals, thereby making the brightness of the screen non-uniform.

SUMMARY OF THE INVENTION

Accordingly, it is an aspect of the present invention to provide an LCD device having more uniform brightness through reduction in the delay difference of the gate signals.

In accordance with an aspect of the invention, a liquid crystal display having a plurality of pixels and driving transistors each having gate, source and drain electrodes, characterized in that the pixels of the display are constructed so that the ratio of the parasitic capacities between the gate and each of the source and drain electrodes to the sum of parasitic capacities between the gate and each of the source and drain electrodes plus the liquid crystal capacity plus the storage capacity decreases towards the gate driver.

Expressed mathematically, the ratio $C_p/(C_p+C_{lc}+C_{st})$ decreases towards the gate driver, where C_p is the sum of parasitic capacities between the gate and each of the source and drain electrodes; C_{lc} is the liquid crystal capacity; and C_{st} is the storage capacity.

According to an aspect of the invention, the thin film transistor comprises a pair of channel regions which are separated with the drain electrode disposed therebetween, and the area where the gate electrode and the drain electrode overlap becomes smaller towards the gate driver.

According to an aspect of the invention, the thin film transistor comprises a channel region having a U-shape, the area where the gate electrode and the drain electrode overlap becoming smaller towards the gate driver.

According to an aspect of the invention, the storage capacity of the pixel is uniform.

According to an aspect of the invention, the storage capacity of the pixel becomes larger towards the gate driver.

According to an aspect of the invention, the area where the gate electrode and the source electrode overlap and the area where the gate electrode and the drain electrode overlap are uniform.

According to an aspect of the invention, the pixels are divided into a plurality of blocks which have the same value of $C_p/(C_p+C_{lc}+C_{st})$.

According to an aspect of the invention, the liquid crystal display device further comprises a second substrate which faces the first substrate and where a common electrode is formed; and a liquid crystal layer which is disposed between the first substrate and the second substrate and in a vertically aligned (VA) mode.

According to an aspect of the invention, a pixel electrode cutting pattern is formed on the pixel electrode, and a common electrode cutting pattern is formed on the common electrode.

According to an aspect of the invention, the gate driver comprises a shift register.

According to an aspect of the invention, the pixel is formed in a display region and the shift register comprises a first shift register and a second shift register which are disposed opposite to each other with respect to the display region.

According to an aspect of the invention, the gate line is alternately connected to the first shift register and the second shift register.

According to an aspect of the invention, the pixel electrode extends lengthwise in the direction in which the gate line is extended.

According to an aspect of the invention, three neighboring pixel electrodes in the direction in which the data line extends (hereinafter, the extending direction of the data line) are connected to different gate lines.

According to an aspect of the invention, two of the three neighboring pixel electrodes in the extending direction of the data line are connected to the same data line.

According to an aspect of the invention, the three neighboring pixel electrodes in the extending direction of the data line are driven sequentially.

BRIEF DESCRIPTION OF THE DRAWINGS

The above and/or other aspects of the present invention will become apparent and more readily appreciated from the following description of the exemplary embodiments, taken in conjunction with the accompanying drawings, in which:

FIG. 1 is a arrangement view of a first substrate in an LCD device according to a first exemplary embodiment of the present invention;

FIG. 2 is an enlarged arrangement view of the first substrate in the LCD device according to the first exemplary embodiment of the present invention;

FIG. 3 is an arrangement view of one pixel in the LCD device according to the first exemplary embodiment of the present invention;

FIG. 4 is a sectional view taken along line IV-IV in FIG. 3;

FIG. 5 illustrates driving the LCD device according to the first exemplary embodiment of the present invention;

FIG. 6 illustrates transmittance according to a pixel voltage in the LCD device according to the first exemplary embodiment of the present invention;

FIG. 7 is an equivalent circuit diagram of one pixel in the LCD device according to the first exemplary embodiment of the present invention;

FIGS. 8A through 8C illustrate pixel voltage difference due to delay of a gate signal;

FIG. 9 illustrates C_{gs} variation in the LCD device according to the first exemplary embodiment of the present invention;

FIG. 10 is an arrangement view of a first substrate in an LCD device according to a second exemplary embodiment of the present invention;

FIG. 11 illustrates C_{gs} variation in the LCD device according to the second exemplary embodiment of the present invention;

FIG. 12 illustrates a first substrate in an LCD device according to a third exemplary embodiment of the present invention;

FIG. 13 illustrates C_{gs} variation in the LCD device according to the third exemplary embodiment of the present invention;

FIG. 14 illustrates C_{gd} variation in an LCD device according to a fourth exemplary embodiment of the present invention;

FIG. 15 illustrates C_{st} variation in an LCD device according to a fifth exemplary embodiment of the present invention; and

FIG. 16 illustrates C_{st} variation in an LCD device according to a sixth exemplary embodiment of the present invention.

DETAILED DESCRIPTION

In the following description, if a layer is said to be formed 'on' another layer, then a third layer may be disposed between the two layers or the two layers may be contacted with each other. In other words, it will be understood that when an element such as a layer, film, region, or substrate is referred to as being "on" another element, it can be directly on the other element or intervening elements may also be present. Further, a layer is said to be formed 'right on' another layer, it will be understood that the two layers contact with each other.

It should be noted that a pixel unit refers to a unit to display a screen where different colors of light from a plurality of pixels are mixed to provide light with desired color and brightness. For example, a red pixel, a blue pixel, and a green pixel form into one pixel unit.

Hereinafter, an LCD device according to exemplary embodiments of the present invention will be described with reference to FIGS. 1 through 5

Referring to FIG. 4, an LCD device 1 includes a first substrate 100 where thin film transistors are formed, a second substrate 200 which faces the first substrate 100 and where color filters 231 are formed, and a liquid crystal layer 300 disposed between the substrates 100 and 200.

To start with the first substrate 100, a gate wire 121 and 122 is formed on a first insulating substrate 111. The gate wire 121 and 122 may be a metal single layer or metal multi layers. The gate wire 121 and 122 includes a gate line 121 which extends

horizontally in a display region and a gate electrode 122 connected to the gate line 121.

A shift register 123 is formed in a non-display region and connected to the gate line 121. The shift register 123, as a gate driver, drives the gate line 121, e.g., applies a gate-on voltage and a gate-off voltage to the gate line 121.

The shift register 123 includes a first shift register 123a disposed on a left side of a display region and a second shift register 123b disposed on a right side of the display region. Referring to FIG. 2, the first shift registers 123a are connected to odd numbered gate lines 121, and the second shift registers 123b are connected to even numbered gate lines 121. Even though it is not shown, the first shift registers 123a are electrically connected to one another, and the second shift registers 123b are electrically connected to one another.

The shift register 123 is formed while forming the first substrate 100 and may include a plurality of thin film transistors.

A gate insulating layer 131 is made of silicon nitride (SiN_x) or the like and formed on the first insulating substrate 111 to cover the gate wire 121 and 122.

A semiconductor layer 132 is made of amorphous silicon or the like and formed on the gate insulating layer 131 over the gate electrode 122. An ohmic contact layer 133 is made of silicide or n+ hydrogenated amorphous silicon which is highly doped with n-type impurities, and formed on the semiconductor layer 132. The ohmic contact layer 133 is removed in a channel region between a source electrode 142 and a drain electrode 143.

A data wire 141, 142, 143, 144 and 145 is formed on the ohmic contact layer 133 and the gate insulating layer 131. The data wire 141, 142, 143, 144 and 145 may be a metal single layer or metal multi layers. The data wire 141, 142, 143, 144 and 145 includes a data line 141 which extends vertically to intersect the gate line 121 to form a pixel, the source electrode 142 which is branched from the data line 141 and extends over the ohmic contact layer 133, the drain electrode 143 separated from the source electrode 142 and formed on a part of the ohmic contact layer 133 opposite to the source electrode 142, a data pad 144 which extends from the data line 141 to be disposed in the non-display region, and a storage electrode line 145 formed parallel with the data line 141. The storage electrode line 145 forms storage capacity C_{st} along with a pixel electrode 161. The storage electrode line 145 may receive a common voltage.

The data pad 144 is connected to a data driver (not shown) to receive a data signal. The data pad 144 is formed to be wider as compared with the data line 141.

A passivation layer 151 is formed on the data wire 141, 142, 143, 144 and 145 and a portion of the semiconductor layer 132 which is not covered with the data wire 141, 142, 143, 144 and 145. A contact hole 152 is formed in the passivation layer 151 to expose the drain electrode 143.

The pixel electrode 161 is formed on the passivation layer 151. The pixel electrode 161 is made of a transparent conductive material such as indium tin oxide (ITO) or indium zinc oxide (IZO). The pixel electrode 161 is connected to the drain electrode 143 through the contact hole 152. A pixel electrode cutting pattern 162 is formed on the pixel electrode 161.

The pixel electrode cutting pattern 162 is formed to divide the liquid crystal layer 300 into a plurality of domains along with a common electrode cutting pattern 252 (described later).

The pixel electrode 161 has a rectangular shape which extends along an extending direction of the gate line 121.

Three neighboring pixel electrodes 161 in an extending direction of the data line 141, i.e., three pixels, form into a

pixel unit as a unit of a screen. The three pixel electrodes **161** are connected to different gate lines **121**, respectively. The pixel electrodes **161** are connected alternately to the data line **141** on the left and to data line **141** on the right along the extending direction of the data line **141**.

In a conventional layout, three pixel electrodes in one pixel unit are disposed in the extending direction of the gate line and connected to different gate lines respectively. In a layout according to the present embodiment, however, the number of gate lines **121** increases by three times, while the number of data lines **141** decreases by one-third as compared with the conventional layout to drive the same number of pixels.

Generally, a circuit to drive the data line **141** is more complicated and expensive than a circuit to drive the gate line **121**. In the present exemplary embodiment, the circuit for the data line **141** is reduced as the number of data lines **141** decreases by one-third, thereby reducing the manufacturing cost. On the other hand, as the number of gate lines **121** increases by three times, the cost of manufacturing the circuit for the gate line **121** may increase. In the present embodiment, however, the gate line **121** is driven by the shift register **123** formed on the first substrate **100**, and thus the cost of manufacturing the circuit does not increase.

Meanwhile, the pixel electrode **161** extends lengthwise in the extending direction of the gate line **121**, and thus an interval between the gate lines **121** decreases. Thus, the shift register **123** has a spatial limitation when being formed. In the present embodiment, however, as the shift register **123** is provided opposite sides of the display region, it is not difficult to provide a space for the shift register **123**.

Next, the second substrate **200** will be described in the following. A black matrix **221** is formed on a second insulating substrate **211**. The black matrix **221** is disposed between a red, green and blue filters to divide the filters, and prevents light from being irradiated directly to a thin film transistor **T** disposed on the first substrate **100**. The black matrix **221** is typically made of a photoresist organic material including a black pigment. The black pigment may be carbon black, titanium oxide or the like.

The color filter layer **231** includes the red, green and blue filters which are alternately disposed and separated by the black matrix **221**. The color filter layer **231** endows colors to light irradiated from the backlight unit (not shown) and passing through the liquid crystal layer **300**. The color filter layer **231** is generally made of a photoresist organic material.

An overcoat layer **241** is formed on the color filter layer **231** and the black matrix **231** exposed between the color filter layers **221**. The overcoat layer **241** provides a flat surface to the color filter **231** and protects the color filter **231**. The overcoat layer **241** may include photoresist acrylic resin.

A common electrode **251** is formed on the overcoat layer **241**. The common electrode **251** is made of a transparent conductive material such as indium tin oxide (ITO), indium zinc oxide (IZO), or the like. The common electrode **251** together with the pixel electrode **161** of the thin film transistor substrate **100** applies a voltage to the liquid crystal layer **300** thin film transistor.

The common electrode cutting pattern **252** is formed on the common electrode **251**. The common electrode cutting pattern **252** divides the liquid crystal layer **300** into a plurality of domains along with the pixel electrode cutting pattern **162** of the pixel electrode **161**.

The pixel electrode cutting pattern **162** and the common electrode cutting pattern **252** may have various shapes. In other exemplary embodiments, protrusions may be provided to divide the liquid crystal layer **300** into a plurality of domains instead of the cutting patterns **162** and **252**.

The liquid crystal layer **300** is disposed between the first substrate **100** and the second substrate **200**. The liquid crystal layer **300** is in a vertically aligned (VA) mode, where liquid crystal molecules are aligned perpendicular to the substrates **100** and **200** in a lengthwise direction between the substrates **100** and **200** under a voltage-off state. The liquid crystal molecules with negative dielectric anisotropy are oriented perpendicularly to an electric field in a voltage-on state.

However, if the pixel electrode cutting pattern **162** and the common electrode cutting pattern **252** are not formed, the orientation of the liquid crystal molecules is not determined. Accordingly, the liquid crystal molecules are disorganized, and thus a disclination line is formed in an interface between the liquid crystal molecules different in the orientation. The pixel electrode cutting pattern **162** and the common electrode cutting pattern **252** generate a fringe field when a voltage is applied to the liquid crystal layer **300**, thereby determining the orientation of the liquid crystal molecules. Also, the liquid crystal layer **300** is divided into a plurality of domains depending on the arrangement of the pixel electrode cutting pattern **162** and the common electrode cutting pattern **252**.

Referring to FIG. 5, driving the LCD device **1** will be described.

When the gate-on voltage is provided to the (n-1)th gate line **121**, the thin film transistor **150** connected to the (n-1)th gate line **121** is turned on. Accordingly, the pixel electrodes **161** disposed in a row (a) and connected to the (n-1)th gate line **121** are turned on.

Then, the gate-on voltage is provided to the (n)th gate line **121**, so that the pixel electrodes **161** disposed in a row (b) and connected to the (n)th gate line **121** are turned on.

Likewise, when the gate-on voltage is provided to the (n+1)th gate line **121**, the pixel electrodes **161** disposed in a row (c) and connected to the (n+1)th gate line **121** are turned on. Accordingly, display of one pixel unit is completed. For the display of one pixel unit, three gate lines **121** are sequentially driven, and accordingly the data line **141** provides a data voltage for each pixel electrode **161**.

Here, a polarity of voltages applied to the pixel electrodes **161** is adjusted in a dot inversion type.

As described above, three pixel electrodes **161** in one pixel unit are driven not at the same time but sequentially. Further, the gate-on voltage is provided three times for driving one pixel unit.

The LCD device **1** according to the first exemplary embodiment is in a normally black mode and has transmittance varied according to a pixel voltage shown in FIG. 6. Transmittance variation in a low gray scale voltage in area A of FIG. 6 is about three times as drastic as that in an LCD device with twisted nematic (TN) liquid crystal molecules.

In the foregoing LCD device **1**, the gate line **121** receives the gate signal through the shift register **123** connected thereto. Because of resistance of the gate line **121**, a thin film transistor adjacent to the shift register **123** receives a gate signal which is less delayed, and a pixel electrode far from the shift register **123** receives a gate signal which is delayed a lot.

Hereinafter, brightness difference according to delay of the gate signal will be described with reference to FIGS. 7 through 8C.

A kickback voltage is expressed as equation 1.

$$V_{kb} = (V_{on} - V_{off}) * C_p / (C_l + C_{st} + C_p) \quad \text{<Equation 1>}$$

It is noted that C_p indicates a sum of parasitic capacity C_{gs} between the gate electrode and the source electrode and parasitic capacity C_{gd} between the gate electrode and the drain

electrode; C_{lc} denotes liquid crystal capacity; C_{st} denotes storage capacity; V_{on} , gate-on voltage; and V_{off} denotes gate-off voltage.

If the gate signal is substantially delayed, the gate-on voltage is not applied smoothly, thus the kickback voltage becomes low. The kickback voltage becomes higher for a negative pixel voltage than for a positive pixel voltage.

FIGS. 8A and 8B illustrate the kickback voltage at a first pixel disposed at the leftmost side where the gate signal is delayed less and the kick back voltage at a second pixel disposed at the rightmost side where the gate signal is substantially more delayed.

In the first pixel of FIG. 8A, the kickback voltage is 1V when a positive pixel voltage is applied, and the kickback voltage is 1.2V when a negative pixel voltage is applied. In the second pixel of FIG. 8B, the kickback voltage is 0.8V both when a positive pixel voltage is applied and when a negative pixel voltage is applied.

Thus, the ultimate root mean square voltage which remains at the pixel is higher in the first pixel than in the second pixel. As the brightness difference becomes greater depending on the difference in pixel voltage in a low gray scale voltage illustrated in FIG. 7, the part corresponding to the first pixel appears brighter on the screen.

Referring to FIG. 8C, the gate signal is less delayed from right to left in pixels connected to the first shift register **123a** on the left side. Accordingly, the kickback voltage V_{kb} becomes higher and the screen corresponding thereto becomes brighter from right to left. On the contrary, the gate signal is less delayed from left to right in pixels connected to the second shift register **123b** on the right side. Accordingly, the kickback voltage V_{kb} becomes higher and the screen corresponding thereto becomes brighter from left to right.

As described above, the brightness varies on the right and the left portions of the screen depending on the position of the shift register **123**, and accordingly a transverse line is seen on the screen. This problem is more serious in large-size LCD devices where the gate signal is delayed more because of the longer gate lines.

In exemplary embodiments of the present invention, the foregoing problem is solved by adjusting parasitic capacity C_p and/or storage capacity C_{st} . In the first exemplary embodiment, the parasitic capacity C_p , specifically, the parasitic capacity C_{gs} between the gate electrode **122** and the source electrode **142** is adjusted, which will be described with FIG. 9.

In the left pixel of the pixels connected to the first shift register **123a**, the area where the gate electrode **122** and the source electrode **142** overlap is relatively small. On the contrary, in the right pixel of the pixels connected to the first shift register **123a**, the area where the gate electrode **122** and the source electrode **142** overlap is relatively large. That is, in the pixels, the area where the gate electrode **122** and the source electrode **142** overlap decreases towards the first shift register **123a**, thereby reducing the parasitic capacity C_{gs} .

The value of $(V_{on}-V_{off})$ increases towards the first shift register **123a**, while the parasitic capacity C_{gs} decreases towards the first shift register **123a**. In equation 1, as the kickback voltage V_{kb} is proportional to the parasitic capacity C_p , the difference between the kickback voltages of the pixels connected to the first shift register **123a** decreases. Namely, the variation of parasitic capacity C_p compensates for the variation of the value of $(V_{on}-V_{off})$, thereby decreasing the difference between the kickback voltages of the pixels.

The difference between the kickback voltages of the pixels may be within $\pm 10\%$ in the positive pixel voltage and in the negative pixel voltage, respectively.

On the other hand, in pixels connected to the second shift register **123b**, the parasitic capacity C_{gs} decreases towards the right. Thus, the difference between the kickback voltages of the pixels connected to the second shift register **123b** decreases.

In the aforementioned first exemplary embodiment, the difference between the kickback voltages V_{kb} of the pixels decreases, thereby improving the display quality.

Referring to FIGS. 10 and 11, a second exemplary embodiment of the present invention will be described.

The shift register **123**, a gate driver, is formed only on the left side of a display region. The pixel electrode **161** extends lengthwise along an extending direction of the data line **141**.

In the second exemplary embodiment, the number of gate lines **121** decreases by one-third, while the number of data lines **141** increases by three times as compared with those of the first exemplary embodiment.

As the shift register **123** is formed only on the left side of the display region, the screen is displayed more brightly on the left part of the display region which is adjacent to the shift register **123**.

In the present embodiment, the parasitic capacity is adjusted to reduce the brightness difference as was explained in the first exemplary embodiment, and therefore the description thereof will be omitted.

Accordingly, the difference between the kickback voltages of pixels on the left side and the right side decreases, and thus the brightness of the screen becomes more uniform.

Referring to FIGS. 12 and 13, a third exemplary embodiment of the present invention will be described.

A first substrate **100** further includes a gate driving chip **126** and a flexible film **125**, and a gate line **121** is connected to a gate pad **124** which is disposed in a non-display region.

A metal pattern (not shown) is formed on the flexible film **125** and in contact with the gate pad **124**. The gate driving chip **126** drives the gate line **121** through the metal pattern and the gate pad **124**. In other exemplary embodiments, the gate driving chip **126** may be mounted directly on a first insulating substrate **111** without the flexible film **125**.

As described in the second exemplary embodiment, the gate pad **124** is formed only on the left side of the display region. Thus, a screen is displayed brighter on its left part of the display region which is adjacent to the gate pad **124**.

In the present embodiment, parasitic capacity is adjusted to reduce the brightness difference, as explained in the first exemplary embodiment, and repetitive description thereof will be omitted.

Accordingly, the difference between the kickback voltages of pixels on the left side and the right side decreases, and thus the brightness of a screen becomes more uniform.

Referring to FIG. 14, a fourth exemplary embodiment of the present invention will be described.

In the present embodiment, parasitic capacity C_{gd} between the gate electrode **122** and the drain electrode **143** is adjusted to reduce brightness differences.

A pair of channel regions of a thin film transistor **T** is provided with the drain electrode **143** disposed therebetween. In this structure, although the drain electrode **143** and the gate electrode **122** are misaligned a little, a predetermined channel region is ensured.

In the left pixel of the pixels connected to a first shift register **123a**, the area where the gate electrode **122** and the drain electrode **143** overlap is relatively small. On the contrary, in the right pixel of the pixels connected to the first shift register **123a**, the area where the gate electrode **122** and the drain electrode **143** overlap is relatively large. That is, in the pixels, the area where the gate electrode **122** and the drain

electrode **143** overlap decreases as towards the first shift register **123a**, thereby reducing the parasitic capacity Cgd.

The value of (Von-Voff) increases towards the first shift register **123a**, while parasitic capacity Cgs decreases towards the first shift register **123a**. In equation 1, as the kickback voltage Vkb is proportional to parasitic capacity Cp, the difference between kickback voltages of the pixels connected to the first shift register **123a** decreases. Accordingly, the variation of the parasitic capacity Cp compensates for the variation of the value of (Von-Voff), thereby maintaining the kickback voltages of the pixels.

On the other hand, in pixels connected to the second shift register **123b**, the parasitic capacity Cgs decreases towards the right. That is, the variation of parasitic capacity Cp compensates for the variation of the value of (Von-Voff), thereby decreasing the difference between the kickback voltages Vkb of the pixels.

In the aforementioned fourth exemplary embodiment, the difference between the kickback voltages Vkb of the pixels decreases, thereby improving a display quality.

Referring to FIG. 15, a fifth exemplary embodiment of the present invention will be described. In the present embodiment, storage capacity Cst is adjusted to reduce brightness differences.

In the left pixel of the pixels connected to a first shift register **123a**, the area where a storage electrode line **145** and a pixel electrode **161** overlap is relatively large. On the contrary, in a right pixel of the pixels connected to the first shift register **123a**, the area where the storage electrode line **145** and the pixel electrode **161** overlap is relatively small. That is, in the pixels, the area where the storage electrode line **145** and the pixel electrode **161** overlap increases towards the first shift register **123a**, thereby increasing the storage capacity Cst.

The value of (Von-Voff) increases towards the first shift register **123a**, and storage capacity Cst increases towards the first shift register **123a**. In equation 1, as the kickback voltage Vkb is in inverse proportion to the storage capacity Cst, the difference between kickback voltages of the pixels connected to the first shift register **123a** decreases. Accordingly, the variation of the storage capacity Cst compensates for the variation of the value of (Von-Voff), thereby decreasing the difference between the kickback voltages Vkb of the pixels.

On the other hand, in pixels connected to the second shift register **123b**, the storage capacity Cst increases towards the right. Thus, the difference between the kickback voltages Vkb of the pixels connected to the second shift register **123b** decreases.

In the aforementioned fifth exemplary embodiment, the difference between the kickback voltages Vkb of the pixels decreases, thereby improving the display quality.

Referring to FIG. 16, a sixth exemplary embodiment of the present invention will be described.

Storage capacity Cst of pixels which correspond to odd numbered gate lines **121** connected to a left shift register **123** decreases towards the right. On the other hand, storage capacity Cst of pixels which correspond to even numbered gate lines **121** connected to a right shift register **123** increases towards the right.

In the sixth exemplary embodiment, the storage capacity Cst of the pixels varies stepwise, and the pixels are divided into a plurality of blocks which have the same storage capacity. In the sixth exemplary embodiment, it is easy to design the first substrate **100**.

The exemplary embodiments of the present invention may be modified variously. For example, at least two of the two

parasitic capacities Cgs and Cds and the storage capacity Cst may be changed at the same time.

As described above, the present invention provides an LCD device in which brightness non-uniformity due to a delay difference of a gate signal is reduced.

Although a few exemplary embodiments of the present invention have been shown and described, it will be appreciated by those skilled in the art that changes may be made in these embodiments without departing from the principles and spirit of the invention, the scope of which is defined in the appended claims and their equivalents.

What is claimed is:

1. A liquid crystal display device comprising:

a first substrate having a plurality of pixels formed in a display region, each pixel comprising a thin film transistor and a pixel electrode electrically connected to the thin film transistor;

a second substrate facing the first substrate; and

a liquid crystal layer interposed between the first substrate and the second substrate,

the first substrate comprising a gate line and a data line; and a gate driver,

the thin film transistor comprising

a gate electrode electrically connected to the gate line;

a source electrode electrically connected to the data line; and

a drain electrode electrically connected to the pixel electrode, wherein a parasitic capacity value of a parasitic capacity between the gate electrode and the source electrode is smaller for a first pixel than for a second pixel that is disposed farther from the gate driver than the first pixel.

2. The liquid crystal display device according to claim 1, wherein the thin film transistor comprises a U-shape channel region, and an area where the gate electrode and the drain electrode overlap becomes smaller towards the gate driver.

3. The liquid crystal display device according to claim 1, wherein a storage capacity of the pixel becomes larger towards the gate driver.

4. The liquid crystal display device according to claim 1, wherein a first portion of the source electrode is disposed between the data line and the drain electrode in an arrangement view of the liquid crystal display device, and the drain electrode is disposed between the first portion of the source electrode and a second portion of the source electrode in the arrangement view of the liquid crystal display device.

5. The liquid crystal display device according to claim 1, wherein the pixel electrode extends lengthwise in an extending direction of the gate line.

6. A liquid crystal display device comprising:

a first substrate having a plurality of pixels formed in a display region, each pixel comprising a thin film transistor and a pixel electrode electrically connected to the thin film transistor;

a second substrate facing the first substrate; and

a liquid crystal layer interposed between the first substrate and the second substrate,

the first substrate comprising

a gate line and a data line; and

a gate driver which comprises a shift register and applies a gate driving signal to the gate line,

the thin film transistor comprising

a gate electrode electrically connected to the gate line;

a source electrode electrically connected to the data line; and

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a drain electrode electrically connected to the pixel electrode, wherein the gate electrode has a constant size towards the gate driver and overlaps the drain electrode, wherein the gate electrode has at least one more protrusion for a first thin film transistor than for a second thin film transistor that is disposed closer to the gate driver than the first thin film transistor, wherein a parasitic capacity value of the pixels decreases towards the gate driver, and wherein the parasitic capacity value includes at least one of a parasitic capacity between the gate electrode and the source electrode and a parasitic capacity between the gate electrode and the drain electrode.

7. The liquid crystal display device according to claim 6, wherein the thin film transistor comprises a U-shape channel region, and an area where the gate electrode and the drain electrode overlap becomes smaller towards the gate driver.

8. The liquid crystal display device according to claim 6, wherein a storage capacity of the pixel becomes larger towards the gate driver.

9. The liquid crystal display device according to claim 6, wherein a first portion of the source electrode is disposed between the data line and the drain electrode in an arrangement view of the liquid crystal display device, and the drain electrode is disposed between the first portion of the source electrode and a second portion of the source electrode in the arrangement view of the liquid crystal display device.

10. The liquid crystal display device according to claim 6, wherein the pixel electrode extends lengthwise in an extending direction of the gate line.

11. The liquid crystal display device according to claim 6, wherein the shift register comprises a first shift register and a second shift register which are disposed opposite to each other with respect to the display region.

12. The liquid crystal display device according to claim 11, wherein the gate line is alternately connected to the first shift register and the second shift register.

13. The liquid crystal display device according to claim 6, wherein the source electrode becomes smaller towards the gate driver.

14. The liquid crystal display device according to claim 1, wherein the gate electrode has a constant size towards the gate driver and overlaps the drain electrode.

15. The liquid crystal display device according to claim 1, wherein the source electrode becomes smaller towards the gate driver.

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16. A liquid crystal display device comprising:
 a first substrate;
 a second substrate facing the first substrate;
 a liquid crystal layer interposed between the first substrate and the second substrate;
 a gate driver disposed at the first substrate;
 a gate line electrically connected to the gate driver;
 a first data line;
 a second data line;
 a first pixel electrode;
 a second pixel electrode;
 a first thin film transistor including: a first gate electrode electrically connected to the gate line, a first source electrode electrically connected to the first data line, and a first drain electrode electrically connected to the first pixel electrode; and

a second thin film transistor disposed closer to the driver than the first thin film transistor, the second thin film transistor including: a second gate electrode electrically connected to the gate line, a second source electrode electrically connected to the second data line, and a second drain electrode electrically connected to the second pixel electrode,

wherein a capacity between the second gate electrode and the second source electrode is less than a capacity between the first gate electrode and the first source electrode.

17. The liquid crystal display device according to claim 16, wherein the second source electrode is smaller than the first source electrode.

18. The liquid crystal display device according to claim 16, wherein the second drain electrode overlaps the second gate electrode, the first drain electrode overlaps the first gate electrode, and the second gate electrode is equal to the first gate electrode in size.

19. The liquid crystal display device according to claim 16, wherein the first source electrode has a curved edge, wherein the drain electrode is disposed between the curved edge and the data line in an arrangement view of the liquid crystal display device.

20. The liquid crystal display device according to claim 16, wherein the second source electrode has two curved edges that are parallel to each other.

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专利名称(译)	液晶显示装置		
公开(公告)号	US8248550	公开(公告)日	2012-08-21
申请号	US12/603529	申请日	2009-10-21
[标]申请(专利权)人(译)	李民CHEOL		
申请(专利权)人(译)	李民哲		
当前申请(专利权)人(译)	三星DISPLAY CO. , LTD.		
[标]发明人	LEE MIN CHEOL		
发明人	LEE, MIN-CHEOL		
IPC分类号	G02F1/136 G02F1/1343 G02F1/1345		
CPC分类号	G02F1/1393 G09G3/3648 G02F1/136213 G09G2320/0223 G09G2320/0219		
助理审查员(译)	穆尼, MICHAEL		
优先权	1020060086747 2006-09-08 KR		
其他公开文献	US20100039575A1		
外部链接	Espacenet USPTO		

摘要(译)

一种液晶显示装置，包括第一基板，所述第一基板包括多个像素，其中形成薄膜晶体管和电连接到所述薄膜晶体管的像素电极，所述第一基板包括栅极线和彼此绝缘交叉的数据线；栅极驱动器，其将栅极驱动信号施加到栅极线，该薄膜晶体管包括连接到栅极线的栅极电极；源极，与数据线连接；以及与像素电极连接的漏电极，像素朝向栅极驱动器减小 $C_p / (C_p + C_{lc} + C_{st})$ 的值（其中， C_p ：栅电极之间的寄生电容之和）以及栅电极和漏电极之间的源电极和寄生电容， C_{lc} ：液晶容量，以及 C_{st} ：存储容量）。

